

Phonon Drag in SiGe Thermoelectric Alloys

Cronin B. Vining

ZT Services, Inc.

Auburn, Alabama USA

Phone: (1) (334) 887-2404

FAX: (1) (334) 887-2604

vining@zts.com

<http://www.zts.com>

APS March Meeting

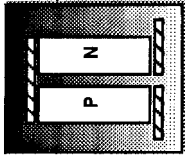
Kansas City

Tuesday March 18, 1997



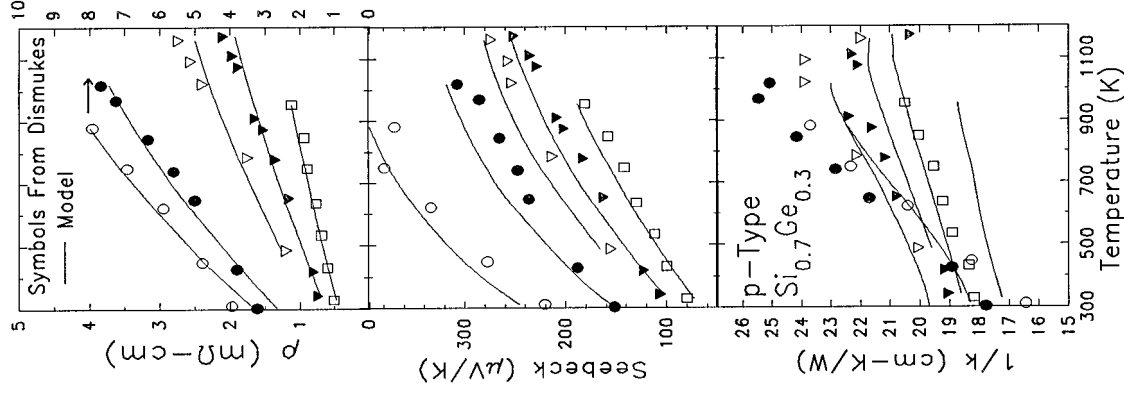
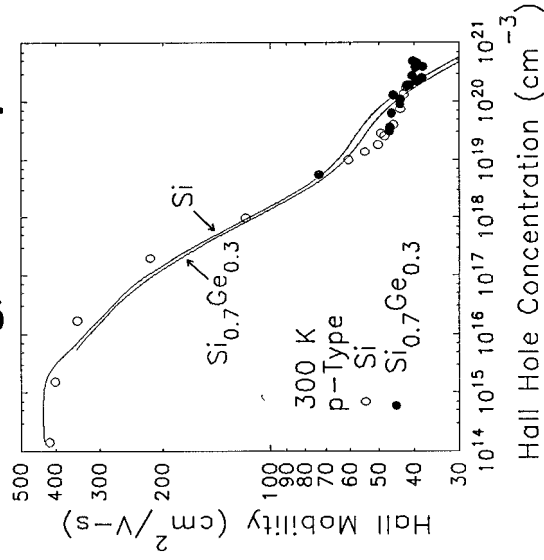
Introduction

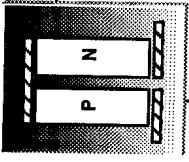
- Phonon-drag is routinely neglected and generally considered small in thermoelectric materials where
 - lattice thermal conductivity is small due to alloying
 - doping level and temperature are relatively high
- But Klemens recently estimated the phonon drag thermopower (S_g) as large as k/e ($=86 \mu\text{V/K}$) at 900 K
 - Klemens, Proc. XV Int. Conf. on Thermoelectrics, 1996, p. 206.
- Calculate S_g and effect on ZT using
 - simple expressions for S_g due to Klemens & Ziman
 - transport model previously developed for SiGe alloys
 - » *no new adjustable parameters*



Transport in SiGe

- Previously modeled electrical and thermal transport in Si-Ge alloys over a range of composition, temperature and doping level.
- n-type: Vining, J. Appl. Phys. 69, 331 (1991).
- p-type: Vining, MRS Symp. Vol. 234, 95 (1991).
- Reproduces experiment with RMSD ~10%
- Neglected Phonon-drag, low Temperature S data.





Phonon Drag Expressions

$$S_g = \frac{3k}{e} \frac{N}{n} \left(\frac{T}{\Theta} \right)^3 \int_0^{\Theta/T} \frac{x^4 e^x}{(e^x - 1)^2} \frac{\tau_{ep}^{-1}}{\tau_{total}^{-1}} dx$$

τ_{ep}^{-1} = rate that phonons are scattered by electrons

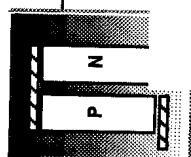
$$\tau_{total}^{-1} = \tau_{ep}^{-1} + \tau_{pp}^{-1} + \text{etc.}$$

= total phonon scattering rate

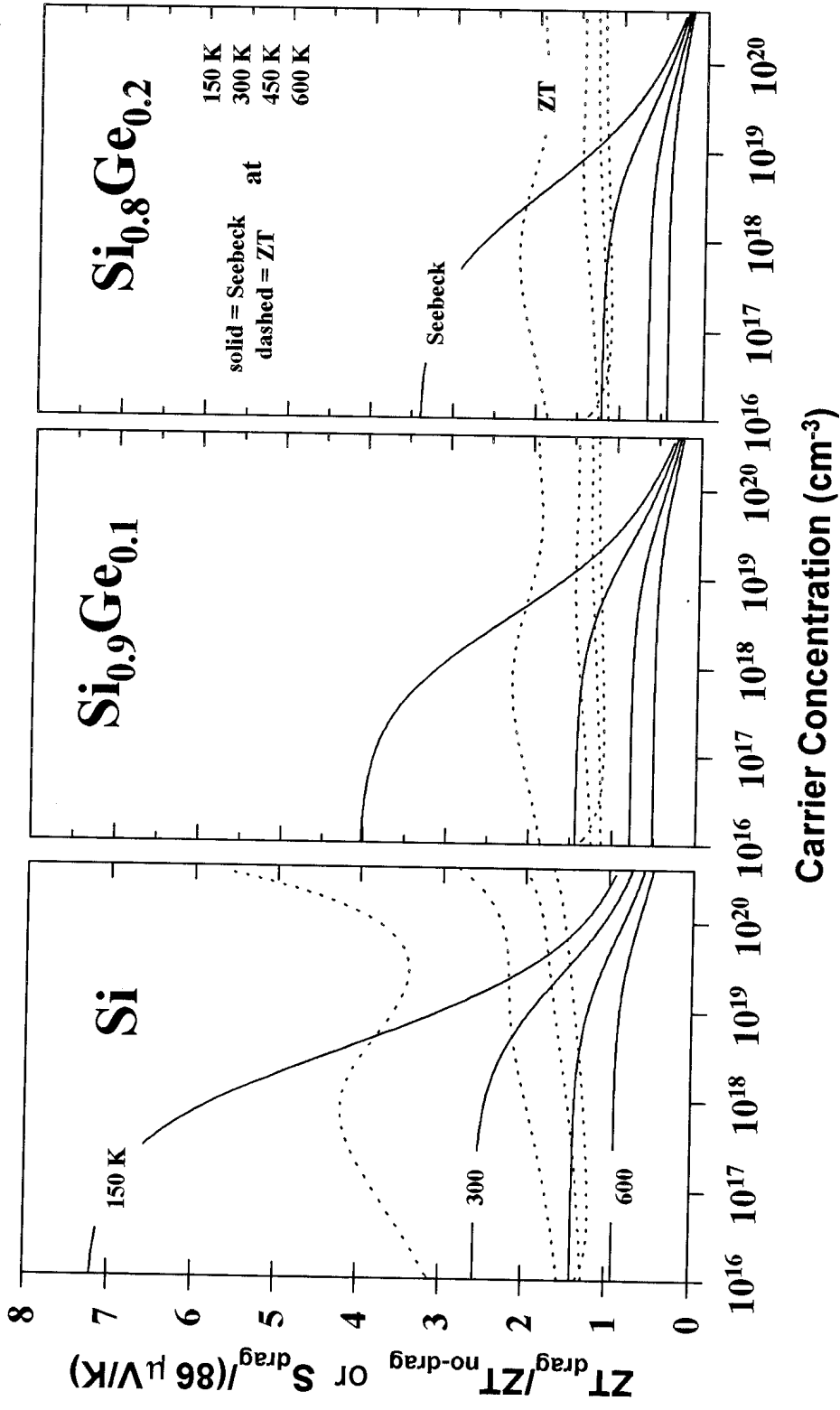
$$S_g \propto \frac{N}{n}$$

$$S_g \propto \frac{\lambda_{lattice}}{\mu}$$

Phonon Drag



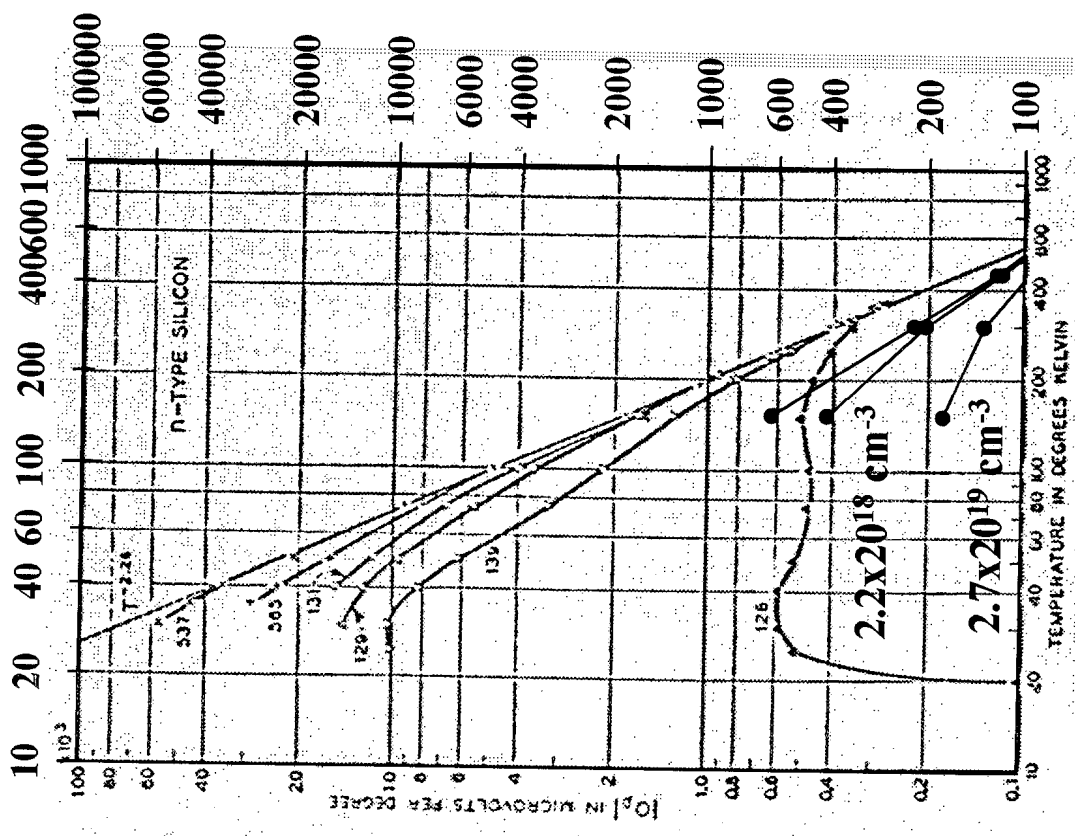
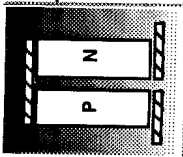
$$ZT = \frac{S^2 \sigma}{\lambda}$$





Conclusions

- Phonon drag can represent a significant contribution to ZT
 - even at high temperatures
 - even at high doping levels
 - even in alloys
- Quantitative evaluation of ZT requires consideration of drag effect
- A unified, quantitative model for the thermoelectric/transport properties of Si is not presently available



S_g in Si

From Geballe and Hull,
Phys Rev. 98(4), 940 (1955)

Fig. 3. Dependence of Q_p upon temperature for n-type samples which differ in size of donor concentration.